

# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

WLJ.05

Application Number

09/548,014

Applicant(s)

Knut Beekman et al.

Filing Date

April 12, 2000

Group Art Unit

2823  
TO BE ASSIGNED

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
me	A	5,242,860	9/1993	NULMAN et al.	—	—	
me	B	5,523,259	6/1996	MERCHANT et al.	—	—	
me	C	5,278,448	1/1994	FUJII	—	—	
me	D	5,843,843	12/1998	LEE et al.	—	—	
me	E	5,462,890	10/1995	HWANG et al.	—	—	



## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
me	F	11040518	2/1999	JAPAN	—	—	✓	
me	G	8274076	10/1996	JAPAN	—	—	✓	
me	H	7142412	6/1995	JAPAN	—	—	✓	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

me	I	C.R. Aita, "Basal orientation aluminum nitride grown...", J. Appl. Phys. 53(3), March 1982, pages 1807-1808.
me	J	Hwan-Chul Lee et al., "Effects of sputtering pressure and nitrogen concentration on the preferred orientation of AlN thin films," Journal of Materials Science: Materials in Electronics (1994) 221-225.

EXAMINER

Michelle Estrada

DATE CONSIDERED

6/1/01

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WLJ.052

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09/548,041

Applicant(s)

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\*EXAMINER

INITIAL

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

me

K

Hiroshi Okano et al., "Preparation of c-Axis Oriented AlN Thin Films by Low-Temperature Reactive Sputtering", Jpn. J. Appl. Phys. Vol. 31 (1992), Pt. 1. No. 10, pages 3446-3451.



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